

**AMENDMENT UNDER 37 C.F.R § 1.116  
EXPEDITED PROSECUTION - ART GROUP 1795**

03500.518677

## PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of: )  
SHOJI SHIBA, ET AL. ) : Examiner: Anca Eoff  
Application No.: 10/577,218 ) : Group Art Unit: 1795  
Filed: April 26, 2006 ) : Confirmation No.: 3411  
For: PHOTOSENSITIVE RESIN )  
COMPOSITION, METHOD OF )  
FORMING LEVEL DIFFERENCE )  
PATTERN USING THE )  
PHOTOSENSITIVE RESIN )  
COMPOSITION, AND METHOD )  
OF PRODUCING INK JET HEAD )  
Date: December 16, 200

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

~~DO NOT ENTER: /A.E./~~

~~1/22/2008~~

## AMENDMENT AFTER FINAL REJECTION

Sir:

a) Introductory Comments:

In response to the final Official Action dated September 18, 2008, kindly amend the above-identified application as follows.